

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Patent Application

Applicant(s): Babich et al.
Docket No.: YOR920030174US1
Serial No : 10/634,667
Filed: August 5, 2003
Group: 1752
Examiner: A C. Walke

Title: Lithographic Antireflective Hardmask Compositions and Uses Thereof

AMENDMENT AND RESPONSE TO OFFICE ACTION

Mail Stop Amendment
Commissioner for Patents
P.O Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the outstanding Office Action, dated July 26, 2006, Applicants submit the following amendments and remarks.